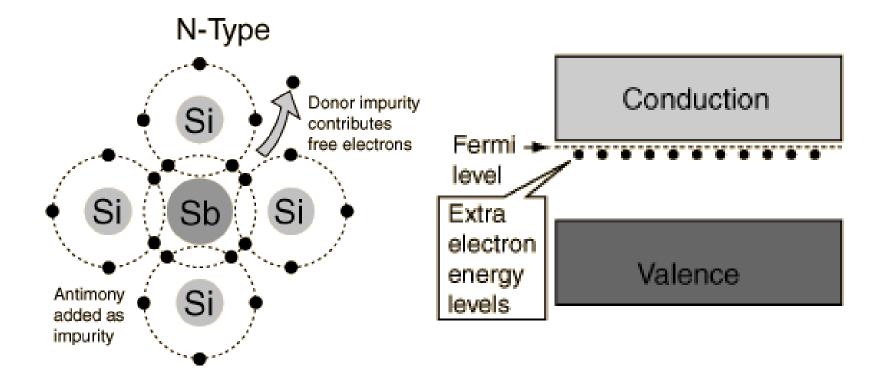
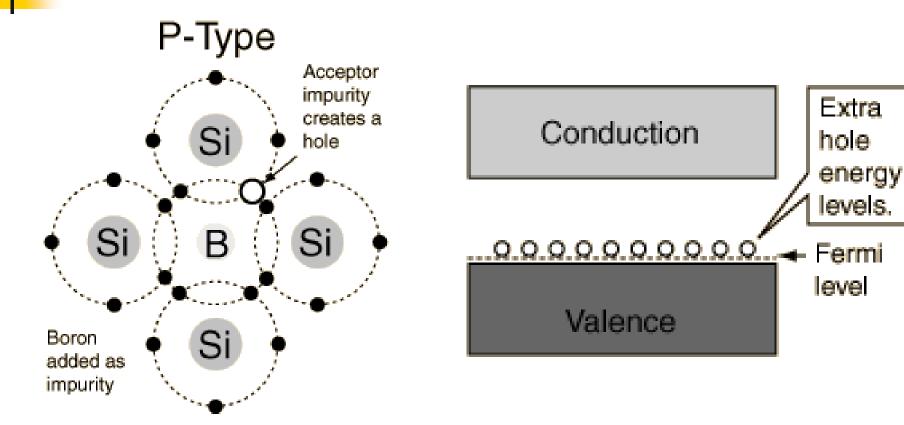
N-Type Semiconductor



The addition of pentavalent <u>impurities</u> such as antimony, arsenic or phosphorous contributes free electrons, greatly increasing the conductivity of the <u>intrinsic semiconductor</u>. Phosphorous may be added by diffusion of phosphine gas (PH3).

P-Type Semiconductor



The addition of trivalent <u>impurities</u> such as boron, aluminum or gallium to an <u>intrinsic semiconductor</u> creates deficiencies of valence electrons, called "holes". It is typical to use B_2H_6 diborane gas to diffuse boron into the silicon material.

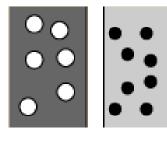
Depletion Region

Electron O Hole

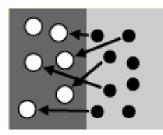
Negative ion from filling of p-type vacancy.

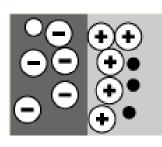


Positive ion from removal of electron from n-type impurity.



In the <u>p-type</u> region there are holes from the acceptor <u>impurities</u> and in the <u>n-type</u> region there are extra electrons.





When a <u>p-n junction</u> is formed, some of the electrons from the n-region which have reached the <u>conduction band</u> are free to diffuse across the junction and combine with holes.

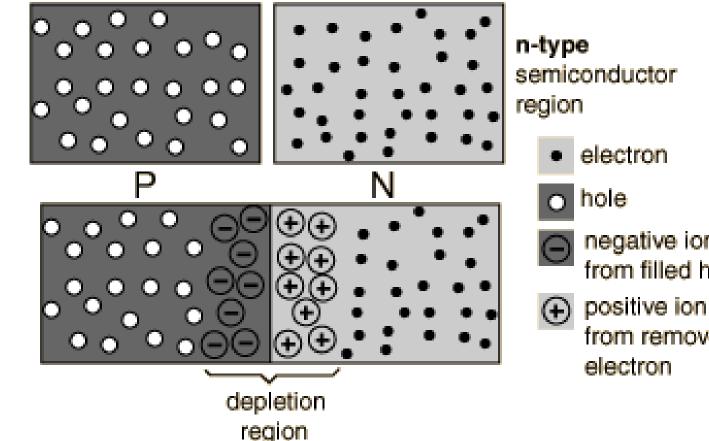
Filling a hole makes a negative ion and leaves behind a positive ion on the n-side. A space charge builds up, creating a <u>depletion region</u> which inhibits any further electron transfer unless it is helped by putting a <u>forward bias</u> on the junction.

Depletion region

When a <u>p-n junction</u> is formed, some of the free electrons in the n-region diffuse across the junction and combine with <u>holes</u> to form negative ions. In so doing they leave behind positive ions at the donor <u>impurity</u> sites.

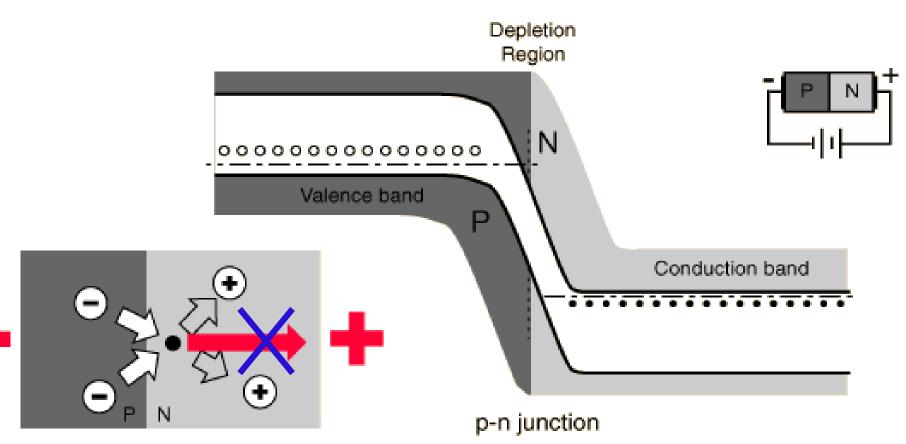
p-type semiconductor region

The combining of electrons and holes depletes the holes in the p-region and the electrons in the n-regioin near the junction.



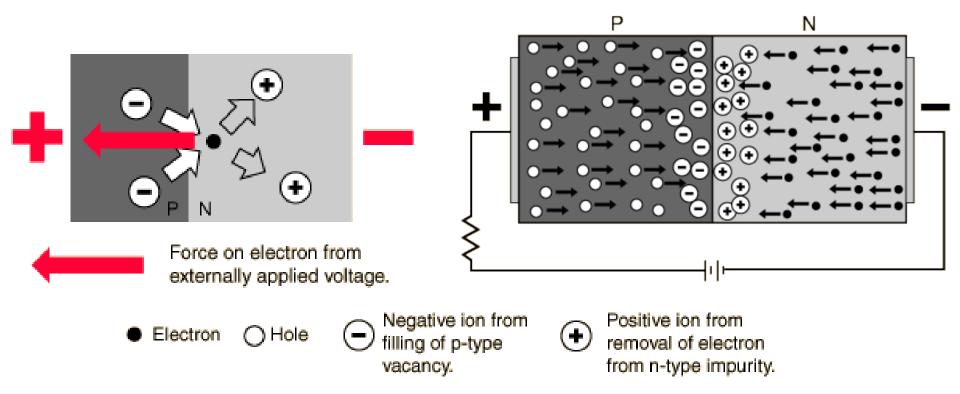
Reverse Biased Conduction of p-n junction

To reverse-bias the <u>p-n junction</u>, the p side is made more negative, making it "uphill" for electrons moving across the junction. The conduction direction for electrons in the diagram is right to left, and the upward direction represents increasing electron energy.

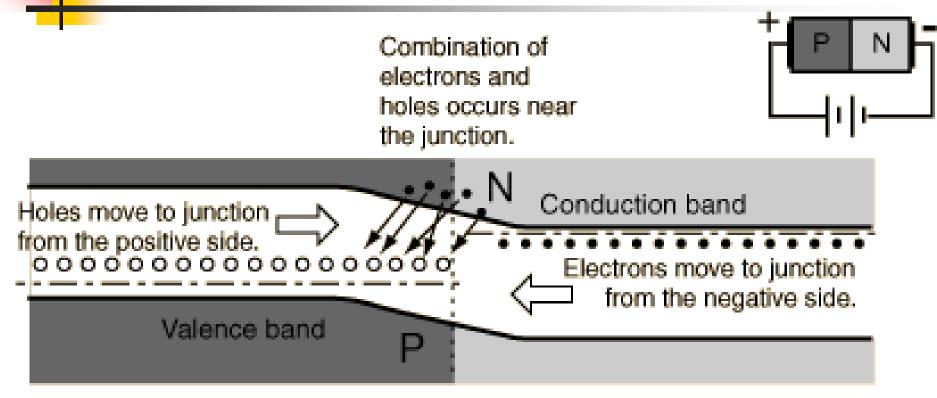


Forward Biased Conduction of p-n junction

The forward current in a <u>p-n junction</u> when it is <u>forward-biased</u> (illustrated below) involves electrons from the <u>n-type</u> material moving leftward across the junction and combining with holes in the <u>p-type</u> material. Electrons can then proceed further leftward by jumping from hole to hole, so the holes can be said to be moving to the right in this process.



Forward Biased Conduction of p-n junction



p-n junction When the <u>p-n junction</u> is <u>forward biased</u>, the electrons in the <u>n-type</u> material which have been elevated to the conduction band and which have diffused across the junction find themselves at a higher energy than the holes in the <u>p-type</u> material. They readily combine with those holes, making possible a continuous forward current through the junction